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 COF_2 has been advocated as a suitable cleaning gas in the Chemical Vapor Deposition (CVD) equipment, used in various processes in the semiconductor industry, and has thus attracted a lot of attention. Compared with other conventional cleaning gases, its global warming potential is as small as a few tens of thousandths. However, little is known about the physical and chemical properties of this molecule. On the other hand, C_3F_6 is invaluable as an etching gas in plasma processing, due to its small global warming potential and a short atmospheric lifetime. However, although there have been some works on photoelectron spectroscopy on these molecules [1-2], there is almost no data on electron scattering.

The experimental apparatus consists of a typical cross-beam method in conjunction with the relative flow technique [3]. The experimental resolution was about 40 meV (FWHM). Electron energy loss spectroscopy (EELS) spectra of COF_2 were measured at 30 eV and 100 eV at the fixed angles of 10° and 5°, respectively, while sweeping the energy losses over the range 5 – 18 eV. EELS spectra of C_3F_6 were measured at 20 eV and 100 eV at the fixed angles of 10° eV at the fixed angles of 10° spectra of C_3F_6 were measured at 20 eV and 100 eV at the fixed angles of 10° and 5°, respectively, while sweeping the energy loss over the range 2 – 14 eV. Part of the results from this study is shown in Fig. 1.

In Fig. 1, the assignment of the observed broad features and the ionization potential (I. P.) for the 7.5 – 10.6 eV are from the VUV photoabsorption spectra of Ref. [2]. The second I. P. for the region 10.6 – 13.8 eV is from Ref. [4]. Three broad structures due to optically allowed transitions have been observed at about 7 eV and 7.5 eV and attributed to the C = C $\pi \rightarrow$ C – F σ^* ; C = C $\pi \rightarrow$ C = C σ^* (both dissociative); and at 8.2 eV, due to C = C $\pi \rightarrow$ C = C π^* excitations. The Rydberg states assignments shown at 7.5



Fig. 1. EELS spectrum of C_3F_6 at the impact energy of 100 eV and angle of 5°.

– 10.6 eV are from Ref. [2], while we have assigned those at 10.6 – 13.8 eV using the standard Rydberg series equation and quantum defect values from Ref. [2]. Distinct differences have been observed in the EELS spectra above 11.5 eV between impact energies of 20 eV and 100 eV. Detailed discussions of these results and those for COF_2 will be presented at the conference.

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